## Homework #4

**Questions 1 -3**: Problems 2, 4, and 5 in Chapter 7 (Campbell's Book)

## **Question 4:**

You want to make a photomask to fabricate a device for the first time. As you don't have any mask design experience, you are concerning about the design errors you may have that can be costly when a quartz mask is used. While printing out transparencies for a talk you are about to give, you come up with an idea of making masks with a laser printer in your lab.

- (1) Theoretically, what is the smallest feature (in microns) you can print with a common high-resolution printer (1200dpi)? If the minimum feature size in your design is 5-µm, what will be the printer resolution required? Does such a printer exist?
- (2) Do some survey to find printing shops that provide printing resolution better than 5000 dpi and check the price of printing?
- (3) Since printer toner and transcendences are not designed for masks, what are the potential problems you may encounter while using the transparency masks for microfabrication?

## **Question 5:**

Calculate the resolutions for the following projection systems (and depth of focus)

- (1) Contact printing with G-line and resist thickness =  $1 \mu m$
- (2) Proximity printing with H-line and resist thickness 1 μm and a mask-wafer separation 3 μm.
- (3) Projection printing with I-line and NA = 0.3
- (4) Projection printing with DUV and NA = 0.2
- (5) Proximity printing with 1 nm X-rays and resist thickness =  $20 \mu m$  and maskwafer separation =  $100\mu m$

Created J. Wang 2007, updated A.G.Andreou 2008.